Amendments to the Claims:

This listing of claims reflects all claim amendments and replaces all prior

versions, and listings, of claims in the application. Material to be inserted is in **bold and**

underline, and material to be deleted is in strikeout or in [[double brackets]] if the

deletion would be difficult to see.

LISTING OF CLAIMS:

1. (Currently amended) A method for making a tandem thin-film photoelectric

converter comprising a transparent electrode layer, at least one amorphous silicon

photoelectric conversion unit, at least one crystalline silicon photoelectric conversion unit,

and a back electrode layer stacked in that order on a transparent insulating substrate, the

method comprising a step of forming the back electrode layer by the method for making a

transparent conductive film comprising introducing an organozinc compound and a

mixed gas in which an oxidizing agent is diluted with a hydrogen gas, into a deposition

chamber to form a transparent conductive film containing zinc oxide as a main

component on a substrate disposed in the deposition chamber, the transparent insulating

substrate being used as the substrate, wherein a temperature of the substrate is from

50°C to 300°C and a pressure in the deposition chamber is from 0.01 to 3 Torr.

2. (Original) The method for making the transparent conductive film according to

Claim 1, wherein the organozine compound is diethylzine.

3. (Original) The method for making the transparent conductive film according to

Claim 1, wherein the oxidizing agent is water.

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4. (Original) The method for making the transparent conductive film according to

Claim 1, wherein a Group III element-containing compound is introduced into the

deposition chamber so that the transparent conductive film containing zinc oxide as the

main component doped with a small amount of the Group III element is formed on the

substrate.

5. (Currently amended) The method for making the transparent conductive film

according to Claim 4, wherein the Group III element-containing compound is at least one

of diborane $(B2H6)(B_2H_6)$ and trimethylaluminum $((CH_3)_3AI)((CH_3)_3AI)$.

6. (Cancelled)

7. (Currently amended) A method for making a tandem thin-film photoelectric

converter comprising a transparent electrode layer, at least one amorphous silicon

photoelectric conversion unit, at least one crystalline silicon photoelectric conversion unit,

and a back electrode layer stacked in that order on a transparent insulating substrate, the

method comprising a step of forming the transparent electrode layer by the method for

making a transparent conductive **film** comprising introducing an organozinc compound

and a mixed gas in which an oxidizing agent is diluted with a hydrogen gas, into a

deposition chamber to form a transparent conductive film containing zinc oxide as a main

component on a substrate disposed in the deposition chamber, the transparent insulating

substrate being used as the substrate, wherein a temperature of the substrate is from

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50°C to 300°C and a pressure in the deposition chamber is from 0.01 to 3 Torr.

8. (Previously presented) The method for making the transparent conductive film

according to Claim 7, wherein the organozine compound is diethylzine.

9. (Previously presented) The method for making the transparent conductive film

according to Claim 7, wherein the oxidizing agent is water.

10. (Previously presented) The method for making the transparent conductive film

according to Claim 7, wherein a Group III element-containing compound is introduced

into the deposition chamber so that the transparent conductive film containing zinc oxide

as the main component doped with a small amount of the Group III element is formed on

the substrate.

11. (Previously presented) The method for making the transparent conductive film

according to Claim 10, wherein the Group III element-containing compound is at least

one of diborane (B_2H_6) and trimethylaluminum ((CH_3)₃Al).

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